# **inter<sub>sil</sub>**"

# HCTS04MS

Radiation Hardened Hex Inverter

# Features

- 3 Micron Radiation Hardened SOS CMOS
- Total Dose 200K RAD (Si)
- SEP Effective LET No Upsets: >100 MEV-cm<sup>2</sup>/mg
- Single Event Upset (SEU) Immunity < 2 x 10<sup>-9</sup> Errors/ Bit-Day (Typ)
- Dose Rate Survivability: >1 x 10<sup>12</sup> RAD (Si)/s
- Dose Rate Upset >10<sup>10</sup> RAD (Si)/s 20ns Pulse
- Latch-Up Free Under Any Conditions
- Military Temperature Range: -55°C to +125°C
- Significant Power Reduction Compared to LSTTL ICs
- DC Operating Voltage Range: 4.5V to 5.5V
- LSTTL Input Compatibility
  - VIL = 0.8V Max
  - VIH = VCC/2
- Input Current Levels Ii  $\leq$  5µA at VOL, VOH

# Description

The Intersil HCTS04MS is a Radiation Hardened Hex Inverter. A logic level on any input forces the output to the opposite logic state.

The HCTS04MS utilizes advanced CMOS/SOS technology to achieve high-speed operation. This device is a member of radiation hardened, high-speed, CMOS/SOS Logic Family.

The HCTS04MS is supplied in a 14 lead Ceramic flatpack (K suffix) or a SBDIP Package (D suffix).

# **Ordering Information**

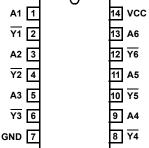
PART NUMBER	TEMPERATURE RANGE	SCREENING LEVEL	PACKAGE
HCTS04DMSR	-55°C to +125°C	Intersil Class S Equivalent	14 Lead SBDIP
HCTS04KMSR	-55°C to +125°C	Intersil Class S Equivalent	14 Lead Ceramic Flatpack
HCTS04D/ Sample	+25 <sup>0</sup> C	Sample	14 Lead SBDIP
HCTS04K/ Sample	+25 <sup>0</sup> C	Sample	14 Lead Ceramic Flatpack
HCTS04HMSR	+25°C	Die	Die





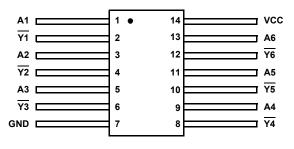
## **Pinouts**







TOP VIEW

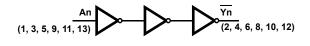


#### TRUTH TABLE

INPUTS	OUTPUTS
An	Yn
L	Н
Н	L

NOTE: L = Logic Level Low, H = Logic level High

# Functional Diagram



#### **Absolute Maximum Ratings**

Supply Voltage0.5V to +7.	ΟV
Input Voltage Range, All Inputs0.5V to VCC +0.	5V
DC Input Current, Any One Input±10r	nA
DC Drain Current, Any One Output±25r	nA
(All Voltage Reference to the VSS Terminal)	
Storage Temperature Range (TSTG)65°C to +150	°C
Lead Temperature (Soldering 10s)+265	°C
Junction Temperature (TJ) +175	°C
ESD Classification Class	s 1

## Reliability Information

Thermal Resistance SBDIP Package	θ <sub>JA</sub> 74ºC/W	θ <sub>JC</sub> 24ºC/W
Ceramic Flatpack Package	116ºC/W	30°C/W
Maximum Package Power Dissipation at +12	5 <sup>o</sup> C Ambien	t
SBDIP Package		0.68W
Ceramic Flatpack Package		0.43W
If device power exceeds package dissipation	capability, pr	ovide heat
sinking or derate linearly at the following rate:		
SBDIP Package	1	3.5mW/ <sup>o</sup> C
Ceramic Flatpack Package		8.6mW/ <sup>o</sup> C

CAUTION: As with all semiconductors, stress listed under "Absolute Maximum Ratings" may be applied to devices (one at a time) without resulting in permanent damage. This is a stress rating only. Exposure to absolute maximum rating conditions for extended periods may affect device reliability. The conditions listed under "Electrical Performance Characteristics" are the only conditions recommended for satisfactory device operation.

#### **Operating Conditions**

Supply Voltage	+4.5V to +5.5V
Input Rise and Fall Times at 4.5V VCC (TR, TF)	100ns/V Max
Operating Temperature Range (T <sub>A</sub> )	55°C to +125°C

Input Low Voltage (VIL)	0.0V to 0.8V
Input High Voltage (VIH)	VCC/2 to VCC

		(NOTE 1)	GROUP A SUB-		LIM	IITS	
PARAMETER	SYMBOL	CONDITIONS	GROUPS	TEMPERATURE	MIN	MAX	UNITS
Quiescent Current	ICC	VCC = 5.5V, VIN = VCC or GND	1	+25°C	-	10	μA
			2, 3	+125°C, -55°C	-	200	μA
Output Current (Sink)	IOL	VCC = 4.5V, VIH = 4.5V, VOUT = 0.4V, VIL = 0V	1	+25°C	4.8	-	mA
(SIIK)		VOUT = 0.4V, VIE = 0V	2, 3	+125°C, -55°C	4.0	-	mA
Output Current	IOH	VCC = 4.5V, VIH = 4.5V, VOUT = VCC -0.4V,	1	+25°C	-4.8	-	mA
(Source)		VIL = 0V	2, 3	+125°C, -55°C	-4.0	-	mA
Output Voltage Low	VOL	VCC = 4.5V, VIH = 2.25V, IOL = 50μA, VIL = 0.8V	1, 2, 3	+25°C, +125°C, -55°C	-	0.1	V
		VCC = 5.5V, VIH = 2.75V, IOL = 50μA, VIL = 0.8V	1, 2, 3	+25°C, +125°C, -55°C	-	0.1	V
Output Voltage High	VOH	VCC = 4.5V, VIH = 2.25V, IOH = -50µA, VIL = 0.8V	1, 2, 3	+25°C, +125°C, -55°C	VCC -0.1	-	V
		VCC = 5.5V, VIH = 2.75V, IOH = -50µA, VIL = 0.8V	1, 2, 3	+25°C, +125°C, -55°C	VCC -0.1	-	V
Input Leakage	IIN	VCC = 5.5V, VIN = VCC or	1	+25°C	-	±0.5	μA
Current		GND	2, 3	+125ºC, -55ºC	-	±5.0	μA
Noise Immunity Functional Test	FN	VCC = 4.5V, VIH = 2.25V, VIL = 0.8V (Note 2)	7, 8A, 8B	+25°C, +125°C, -55°C	-	-	-

#### TABLE 1. DC ELECTRICAL PERFORMANCE CHARACTERISTICS

NOTES:

1. All voltages reference to device GND.

2. For functional tests, VO  $\ge$  4.0V is recognized as a logic "1", and VO  $\le$  0.5V is recognized as a logic "0".

		(NOTES 1, 2)	GROUP A SUB-		LIM	ITS	
PARAMETER	SYMBOL	CONDITIONS	GROUPS	TEMPERATURE	MIN	MAX	UNITS
Input to Yn	TPHL	VCC = 4.5V	9	+25°C	2	18	ns
		VCC = 4.5V	10, 11	+125°C, -55°C	2	20	ns
Input to $\overline{Yn}$	TPLH	VCC = 4.5V	9	+25°C	2	20	ns
		VCC = 4.5V	10, 11	+125°C, -55°C	2	22	ns

#### TABLE 2. AC ELECTRICAL PERFORMANCE CHARACTERISTICS

NOTES:

1. All voltages referenced to device GND.

2. AC measurements assume RL =  $500\Omega$ , CL = 50pF, Input TR = RF = 3ns, VIL = GND, VIH = 3V.

					LIM	IITS	
PARAMETER	SYMBOL	CONDITIONS	NOTES	TEMPERATURE	MIN	MAX	UNITS
Capacitance Power Dissipation	CPD	VCC = 5.0V, f = 1MHz	1	+25°C	-	50	pF
Dissipation			1	+125°C, -55°C	-	95	pF
Input Capacitance	CIN	VCC = 5.0V, f = 1MHz	1	+25°C	-	10	pF
			1	+125°C	-	10	pF
Output Transition Time	TTHL TTLH	VCC = 4.5V	1	+25°C	-	15	ns
	ΓILΠ		1	+125°C	-	22	ns

#### TABLE 3. ELECTRICAL PERFORMANCE CHARACTERISTICS

NOTE:

1. The parameters listed in Table 3 are controlled via design or process parameters. Min and Max Limits are guaranteed but not directly tested. These parameters are characterized upon initial design release and upon design changes which affect these characteristics.

#### TABLE 4. DC POST RADIATION ELECTRICAL PERFORMANCE CHARACTERISTICS

				200K LIM		
PARAMETER	SYMBOL	(NOTES 1, 2) CONDITIONS	TEMPERATURE	MIN	MAX	UNITS
Quiescent Current	ICC	VCC = 5.5V, VIN = VCC or GND	+25°C	-	0.2	mA
Output Current (Sink)	IOL	VCC = 4.5V, VIN = VCC or GND, VOUT = 0.4V	+25 <sup>0</sup> C	4.0	-	mA
Output Current (Source)	IOH	VCC = 4.5V, VIN = VCC or GND, VOUT = VCC -0.4V	+25°C	-4.0	-	mA
Output Voltage Low	VOL	VCC = 4.5V and 5.5V, VIH = VCC/2, VIL = 0.8V, IOL = 50 $\mu$ A	+25°C	-	0.1	V
Output Voltage High	VOH	VCC = 4.5V and 5.5V, VIH = VCC/2, VIL = 0.8V, IOH = -50μA	+25°C	VCC -0.1	-	V
Input Leakage Current	IIN	VCC = 5.5V, VIN = VCC or GND	+25°C	-	±5	μA

#### TABLE 4. DC POST RADIATION ELECTRICAL PERFORMANCE CHARACTERISTICS (Continued)

		(NOTES 1, 2)			RAD IITS	
PARAMETER	SYMBOL	CONDITIONS	TEMPERATURE	MIN	MAX	UNITS
Noise Immunity Functional Test	FN	VCC = 4.5V, VIH = 2.25V, VIL = 0.8V, (Note 3)	+25 <sup>0</sup> C	-	-	-
Input to Yn	TPHL	VCC = 4.5V	+25°C	2	20	ns
	TPLH	VCC = 4.5V	+25°C	2	22	ns

NOTES:

1. All voltages referenced to device GND.

2. AC measurements assume RL =  $500\Omega$ , CL = 50pF, Input TR = TF = 3ns, VIL = GND, VIH = 3V.

3. For functional tests VO  $\ge$  4.0V is recognized as a logic "1", and VO  $\le$  0.5V is recognized as a logic "0".

#### TABLE 5. BURN-IN AND OPERATING LIFE TEST, DELTA PARAMETERS (+25°C)

PARAMETER	GROUP B SUBGROUP	DELTA LIMIT
ICC	5	ЗμА
IOL/IOH	5	-15% of 0 Hour

#### TABLE 6. APPLICABLE SUBGROUPS

CONFORMANCE GROUPS		METHOD	GROUP A SUBGROUPS	READ AND RECORD
Initial Test (Preburn-In)		100%/5004	1, 7, 9	ICC, IOL/H
Interim Test I (Postburn-In)		100%/5004	1, 7, 9	ICC, IOL/H
Interim Test II (Postburn-In)		100%/5004	1, 7, 9	ICC, IOL/H
PDA		100%/5004	1, 7, 9, Deltas	
Interim Test III (Postburn-In)		100%/5004	1, 7, 9	ICC, IOL/H
PDA		100%/5004	1, 7, 9, Deltas	
Final Test		100%/5004	2, 3, 8A, 8B, 10, 11	
Group A (Note 1)		Sample/5005	1, 2, 3, 7, 8A, 8B, 9, 10, 11	
Group B	Subgroup B-5	Sample/5005	1, 2, 3, 7, 8A, 8B, 9, 10, 11, Deltas	Subgroups 1, 2, 3, 9, 10, 11
	Subgroup B-6	Sample/5005	1, 7, 9	
Group D		Sample/5005	1, 7, 9	

NOTE:

1. Alternate Group A testing in accordance with Method 5005 of MIL-STD-883 may be exercised.

#### TABLE 7. TOTAL DOSE IRRADIATION

CONFORMANCE		TEST		READ AND RECORD	
GROUPS	METHOD	PRE RAD	POST RAD	PRE RAD	POST RAD
Group E Subgroup 2	5005	1, 7, 9	Table 4	1, 9	Table 4 (Note 1)

NOTE:

1. Except FN test which will be performed 100% Go/No-Go.

#### TABLE 8. STATIC AND DYNAMIC BURN-IN TEST CONNECTIONS

				OSCILLATOR	
OPEN	GROUND	1/2 VCC = 3V $\pm$ 0.5V	VCC = 6V $\pm$ 0.5V	50kHz	25kHz
STATIC BURN-IN I TEST CONDITIONS (Note 1)					
2, 4, 6, 8, 10, 12	1, 3, 5, 7, 9, 11, 13	-	14	-	-
STATIC BURN-IN II TEST CONNECTIONS (Note 1)					
2, 4, 6, 8, 10, 12	7	-	1, 3, 5, 9, 11, 13, 14	-	-
DYNAMIC BURN-IN I TEST CONNECTIONS (Note 2)					
-	7	2, 4, 6, 8, 10, 12	14	1, 3, 5, 9, 11, 13	-

NOTES:

2. Each pin except VCC and GND will have a resistor of 1K $\Omega\pm5\%$  for dynamic burn-in.

#### TABLE 9. IRRADIATION TEST CONNECTIONS

OPEN	GROUND	VCC = 5V $\pm$ 0.5V
2, 4, 6, 8, 10, 12	7	1, 3, 5, 9, 11, 13, 14

NOTE: Each pin except VCC and GND will have a resistor of 47K $\Omega \pm 5\%$  for irradiation testing. Group E, Subgroup 2, sample size is 4 dice/wafer 0 failures.

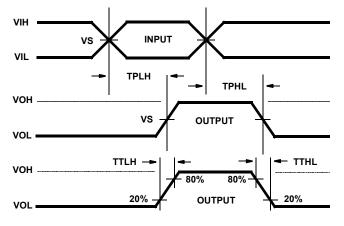
<sup>1.</sup> Each pin except VCC and GND will have a resistor of 10K $\Omega\pm5\%$  for static burn-in.

Wafer Lot Acceptance (All Lots) Method 5007 (Includes SEM)100% Interim Electrical Test 1 (T1)GAMMA Radiation Verification (Each Wafer) Method 1019, 4 Samples/Wafer, 0 Rejects100% Static Burn-In 2, Condition A or B, 24 hrs. min., +125°C min., Method 1015100% Nondestructive Bond Pull, Method 2023100% Interim Electrical Test 2 (T2)Sample - Wire Bond Pull Monitor, Method 2011100% Delta Calculation (T0-T2)Sample - Die Shear Monitor, Method 2019 or 2027100% PDA 1, Method 5004 (Notes 1and 2)100% Internal Visual Inspection, Method 2010, Condition A 10 Cycles100% Interim Electrical Test 3 (T3)100% Constant Acceleration, Method 2001, Condition Per Method 5004100% Interim Electrical Test 3 (T3)100% PIND, Method 2020, Condition A100% PDA 2, Method 5004 (Note 2)100% External Visual100% Constant Acceleration A100% External Visual100% Final Electrical Test100% Initial Electrical Test (T0)100% Final Electrical Test100% Static Burn-In 1, Condition A or B, 24 hrs. min., +125°C min., Method 1015100% Final Cacual Method 2012 (Note 3)100% Static Burn-In 1, Condition A or B, 24 hrs. min., +125°C min., Method 1015300% Final Electrical Test100% Static Burn-In 1, Condition A or B, 24 hrs. min., +125°C min., Method 1015300% Final Electrical Test100% Deta Package Generation (Note 5)300% Final Package Generation (Note 5)	Intersil Space Level Product Flow - 'MS'	
<ul> <li>100% Temperature Cycle, Method 1010, Condition C, 10 Cycles</li> <li>100% Constant Acceleration, Method 2001, Condition per Method 5004</li> <li>100% PIND, Method 2020, Condition A</li> <li>100% PIND, Method 2020, Condition A</li> <li>100% External Visual</li> <li>100% Serialization</li> <li>100% Initial Electrical Test (T0)</li> <li>100% Static Burn-In 1, Condition A or B, 24 hrs. min., +125°C min., Method 1015</li> <li>Equivalent, Method 1015</li> <li>Equivalent, Method 1015</li> <li>Equivalent, Method 1015</li> <li>Equivalent, Method 1015</li> <li>100% Interim Electrical Test</li> <li>100% PDA 2, Method 5004 (Note 2)</li> <li>100% Final Electrical Test</li> <li>100% Fine/Gross Leak, Method 1014</li> <li>100% External Visual, Method 2012 (Note 3)</li> <li>100% External Visual, Method 2009</li> <li>Sample - Group A, Method 5005 (Note 4)</li> </ul>	<ul> <li>Wafer Lot Acceptance (All Lots) Method 5007 (Includes SEM)</li> <li>GAMMA Radiation Verification (Each Wafer) Method 1019, 4 Samples/Wafer, 0 Rejects</li> <li>100% Nondestructive Bond Pull, Method 2023</li> <li>Sample - Wire Bond Pull Monitor, Method 2011</li> <li>Sample - Die Shear Monitor, Method 2019 or 2027</li> </ul>	<ul> <li>100% Delta Calculation (T0-T1)</li> <li>100% Static Burn-In 2, Condition A or B, 24 hrs. min., +125°C min., Method 1015</li> <li>100% Interim Electrical Test 2 (T2)</li> <li>100% Delta Calculation (T0-T2)</li> <li>100% PDA 1, Method 5004 (Notes 1and 2)</li> </ul>
	<ul> <li>10 Cycles</li> <li>100% Constant Acceleration, Method 2001, Condition per Method 5004</li> <li>100% PIND, Method 2020, Condition A</li> <li>100% External Visual</li> <li>100% Serialization</li> <li>100% Initial Electrical Test (T0)</li> <li>100% Static Burn-In 1, Condition A or B, 24 hrs. min., +125°C</li> </ul>	Equivalent, Method 1015 100% Interim Electrical Test 3 (T3) 100% Delta Calculation (T0-T3) 100% PDA 2, Method 5004 (Note 2) 100% Final Electrical Test 100% Fine/Gross Leak, Method 1014 100% Radiographic, Method 2012 (Note 3) 100% External Visual, Method 2009 Sample - Group A, Method 5005 (Note 4)

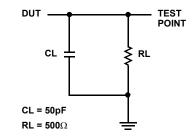
NOTES:

- 1. Failures from Interim electrical test 1 and 2 are combined for determining PDA 1.
- 2. Failures from subgroup 1, 7, 9 and deltas are used for calculating PDA. The maximum allowable PDA = 5% with no more than 3% of the failures from subgroup 7.
- 3. Radiographic (X-Ray) inspection may be performed at any point after serialization as allowed by Method 5004.
- 4. Alternate Group A testing may be performed as allowed by MIL-STD-883, Method 5005.
- 5. Data Package Contents:
  - Cover Sheet (Intersil Name and/or Logo, P.O. Number, Customer Part Number, Lot Date Code, Intersil Part Number, Lot Number, Quantity).
  - Wafer Lot Acceptance Report (Method 5007). Includes reproductions of SEM photos with percent of step coverage.
  - GAMMA Radiation Report. Contains Cover page, disposition, Rad Dose, Lot Number, Test Package used, Specification Numbers, Test equipment, etc. Radiation Read and Record data on file at Intersil.
  - X-Ray report and film. Includes penetrometer measurements.
  - Screening, Electrical, and Group A attributes (Screening attributes begin after package seal).
  - · Lot Serial Number Sheet (Good units serial number and lot number).
  - Variables Data (All Delta operations). Data is identified by serial number. Data header includes lot number and date of test.
  - The Certificate of Conformance is a part of the shipping invoice and is not part of the Data Book. The Certificate of Conformance is signed by an authorized Quality Representative.

# AC Timing Diagrams



AC Load Circuit



## AC VOLTAGE LEVELS

PARAMETER	нстѕ	UNITS
VCC	4.50	V
VIH	3.00	V
VS	1.30	V
VIL	0	V
GND	0	V

## **Die Characteristics**

## DIE DIMENSIONS:

87 x 88 mils 2.20mm x 2.24mm

#### METALLIZATION:

Type: AlSi Metal Thickness:  $11k\dot{A} \pm 1k\dot{A}$ 

# Metallization Mask Layout

GLASSIVATION:

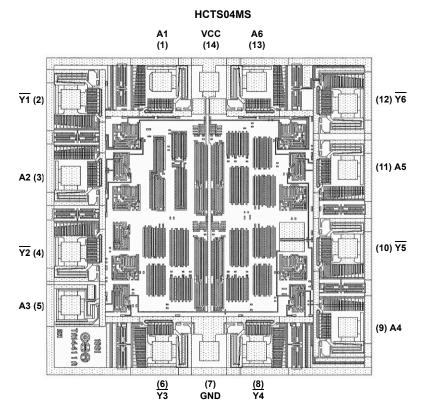
Type: SiO\_2 Thickness: 13kÅ  $\pm$  2.6kÅ

## WORST CASE CURRENT DENSITY:

<2.0 x 10<sup>5</sup>A/cm<sup>2</sup>

## BOND PAD SIZE:

 $100\mu m x 100\mu m$ 4 x 4 mils



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